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APPLICATION NO.	FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/884,193	(06/19/2001	Ronald Patrick Huemoeller	W2K1035	2823	
23504	7590	12/02/2004	EXAMINER			
WEISS & N			ANDUJAR, LEONARDO			
4204 NORTH BROWN AVENUE SCOTTSDALE, AZ 85251				ART UNIT PAPER NUMBER		
50011551122, 112 00201				2826		

DATE MAILED: 12/02/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

•		Application No.		Applicant(s)					
Office Action S	'umman/		09/884,193 HUEMOELLER ET AL		AL.				
Office Action 3	ummary	Examiner		Art Unit	.)				
		Leonardo Andúj		2826	- Pr				
The MAILING DATE of Period for Reply	f this communication app	ears on the cove	r sheet with the c	orrespondence add	Iress				
A SHORTENED STATUTOR THE MAILING DATE OF TH - Extensions of time may be available after SIX (6) MONTHS from the mail - If the period for reply specified above - If NO period for reply is specified above - Failure to reply within the set or exter Any reply received by the Office later earned patent term adjustment. See	IIS COMMUNICATION. under the provisions of 37 CFR 1.1: ng date of this communication. is less than thirty (30) days, a reply ve, the maximum statutory period vided period for reply will, by statute than three months after the mailing	36(a). In no event, how y within the statutory mi will apply and will expire , cause the application	ever, may a reply be tim nimum of thirty (30) day SIX (6) MONTHS from to become ABANDONE	nely filed s will be considered timely, the mailing date of this cord (35 U.S.C. § 133).					
Status									
1) Responsive to commu	inication(s) filed on 16 A	ugust 2004.							
2a) ☐ This action is FINAL .									
3) Since this application	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is								
closed in accordance	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.								
Disposition of Claims			•						
4)⊠ Claim(s) <u>1-25</u> is/are p	ending in the application.								
4a) Of the above claim	4a) Of the above claim(s) is/are withdrawn from consideration.								
5) Claim(s) is/are	allowed.								
6) Claim(s) is/are	rejected.								
7) Claim(s) is/are	objected to.								
8)⊠ Claim(s) <u>1-25</u> are sub	ject to restriction and/or	election requiren	nent.						
Application Papers									
9) ☐ The specification is ob	jected to by the Examine	er.							
10) ☐ The drawing(s) filed or			jected to by the	Examiner.					
	st that any objection to the								
Replacement drawing sl	neet(s) including the correct	tion is required if the	ne drawing(s) is ob	jected to. See 37 CF	R 1.121(d).				
11) The oath or declaration	n is objected to by the Ex	kaminer. Note the	e attached Office	Action or form PT	O-152.				
Priority under 35 U.S.C. § 119									
12) Acknowledgment is ma	ade of a claim for foreign	priority under 3	5 U.S.C. § 119(a)-(d) or (f).					
a) ☐ All b) ☐ Some * c		,		, , , , ,					
· ·-	of the priority document	s have been rec	eived.						
_ · ·	of the priority document			ion No					
	ertified copies of the prio		• •		Stage				
application from	the International Burea	u (PCT Rule 17.	2(a)).		_				
* See the attached detail	ed Office action for a list	of the certified c	opies not receive	ed.					
		,	,						
Attachment(s)									
Notice of References Cited (PTC)	-892)	4) [Interview Summary	(PTO-413)					
2) D Notice of Draftsperson's Patent D	Prawing Review (PTO-948)		Paper No(s)/Mail D	ate	152				
Information Disclosure Statemen Paper No(s)/Mail Date	t(s) (PTO-1449 or PTO/SB/08)		Other:	Patent Application (PTC	-102)				

DETAILED ACTION

Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
 - Claims 1-12, drawn to an integrated circuit, classified in class 257, subclass 778.
 - II. Claims 13-22, drawn to a method for manufacturing an integrated circuit substrate, classified in class 438, subclass 108.
 - III. Claims 23-25, drawn to a tool for embossing a substrate material, classified in class 174, subclass 261.

The inventions are distinct, each from the other because of the following reasons:

- 2. Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, the channels can man be made by chemical etching or by laser ablation.
- 3. Inventions III and I are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case, the tool can be used for embossing a substrate that does not

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include any circuit material such a decorative plastic substrate having letters or other designs.

- 4. Inventions III and I are related as apparatus and product made. The inventions in this relationship are distinct if either or both of the following can be shown: (1) that the apparatus as claimed is not an obvious apparatus for making the product and the apparatus can be used for making a different product or (2) that the product as claimed can be made by another and materially different apparatus (MPEP § 806.05(g)). In this case, the channels of the product of claim I can be made by a chemical etching apparatus or a laser ablation apparatus.
- 5. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 6. Because these inventions are distinct for the reasons given above and the search required for Group I is not required for Groups II and III and the search required for Group II is not required for Group III, restriction for examination purposes as indicated is proper.
- 7. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art because of their recognized divergent subject matter, restriction for examination purposes as indicated is proper.
- 8. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one

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or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by

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a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

9. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Leonardo Andújar whose telephone number is 571-272-

1912. The examiner can normally be reached on Mon through Thu from 9:00 AM to

7:30 PM EST. If attempts to reach the examiner by telephone are unsuccessful, the

examiner's supervisor, Nathan J. Flynn can be reached on 571-272-1915. The fax

phone number for the organization where this application or proceeding is assigned is

703-872-9306. Information regarding the status of an application may be obtained from

the Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

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11/29/2004